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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Dalton et al.
Title: Formation of Low Resistance Via Contacts in Interconnect Structures
Filed: September 19, 2003
Serial No: 10/665,584
Docket No.: YOR920030247US1
Examiner: Thomas L. Dickey
Art Unit: 2826
Confirmation No.: 5258
Customer No.: 27623

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

In response to the Office Action dated October 5, 2004, please amend this application as follows: